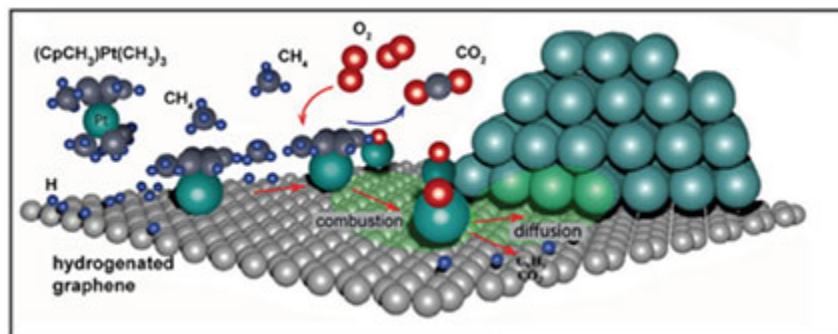


# Facilitating the controlled growth of catalysts and dielectrics on graphene surfaces

Stanford researchers have patented a method of growing catalyst and dielectric nanocrystals on graphene surfaces. Hydrogen plasma treats the graphene surface, controls nanocrystal growth, and maintains graphene's properties while catalysts or dielectrics are deposited via Atomic Layer Deposition. The method is suitable for deposition on graphene, hexagonal boron nitride, or dichalcogenides, including molybdenum sulfide, or tungsten selenide. It's a cost-effective and production compatible way of addressing existing challenges in fuel and photoelectrochemical cells, facilitating top gate transistor device fabrication on graphene, and activating graphene in biological and sensing applications.

## Stage of Research

Researchers used controlled radio-frequency hydrogen plasma to treat graphene and then grow various nanocrystals and dielectric thin films using Atomic Layer Deposition, while retaining the graphene's intrinsic properties. Ongoing research in surface chemistry and devices is underway.



Schematic model of the stages of the Atomic Layer Deposition reaction with pulses of the Pt precursor molecule and O<sub>2</sub>. The initially reactive sites are the hydrogenated sites resulting from the H<sub>2</sub> plasma treatment.

# Applications

- Deposition of catalysts and dielectrics on graphene surfaces for:
  - **Fuel cells, solar cells, photoelectrochemical and water-splitting cells.**
  - **Electronic devices** that require the use of dielectric spacers and top gates.
  - **Biological sensing and diagnostics, and chemical sensing.**

# Advantages

- **Cost effective, compatible with large-scale industrial production, and avoids harsh wet chemistry.**
- **Graphene's** outstanding electronic and thermal transport **properties remain intact.**
- **Nanocrystal** growth, such as **size and density, can be tailored** via treatment of the graphene surface.

# Publications

- Diankov, Georgi, Jihwan An, Joonsuk Park, David JK Goldhaber, and Friedrich B. Prinz. "[Functionalized Graphene-Pt composites for fuel cells and photoelectrochemical cells.](#)" U.S. Patent Application 14/634,791, filed February 28, 2015.

# Patents

- Published Application: [20150247258](#)
- Issued: [9,748,581 \(USA\)](#)

# Innovators

- jihwan an

- Georgi Diankov
- Joonsuk Park
- David Goldhaber;goldhaber gordon;gordo
- Friedrich Prinz

## **Licensing Contact**

### **Luis Mejia**

Senior Licensing Manager, Physical Sciences

[Email](#)